

-	11	(semiconductor near4 (surface adj treatment)) and (electron adj hole adj pair)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/06/23 15:03
-	6	((semiconductor near4 (surface adj treatment)) and (electron adj hole adj pair)) and (IR or infrared)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/06/23 15:04